



PATENT

2811
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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: SCHAUER ET AL 1 PCT
SERIAL NO.: 09/890,656 EXAMINER: THIEN F. TRAN
FILED: AUGUST 2, 2001 GROUP: 2811
TITLE: SEMICONDUCTOR WAFER COMPRISING A THIN EPITAXIAL
SILICON LAYER AND METHOD FOR PRODUCING SAME

#6.
Election
FJOPE
11-8-02

RESPONSE TO RESTRICTION REQUIREMENT

ATTN: BOX NON FEE AMENDMENT
Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

In response to the Office Action dated OCTOBER 1, 2002,
Applicant respectfully responds as follows:

REMARKS

The Patent Examiner has required a restriction to one of the
following two (2) inventions:

Group I: Claims 13-15, drawn to a semiconductor device,
classified in class 257, subclass 56.